Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	1	10/664858	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/01/20 13:32
L2	0	"55611317"	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/01/20 13:32
L3	9	"5611317"	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/01/20 13:33
L4	6	"5561317"	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/01/20 13:39
L5	4	"5731131"	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/01/20 13:40
L6	525780	one adj shot exposure	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/01/20 13:41
L7	65135	one adj shot exposure with mask	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/01/20 13:41
L8	32277	one adj shot exposure with mask with wiring	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/01/20 13:42
L9	1237236	one adj shot exposure with mask with wiring pattern$4	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/01/20 13:42
L10	1214080	one adj shot adj exposure with mask with wiring pattern$4	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/01/20 13:42
L11	1	(one adj shot adj exposure) with mask with wiring with pattern$4	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/01/20 13:43
L12	57	(one adj shot adj exposure) with mask	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/01/20 14:30
L15	408	(one adj shot) with mask	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/01/20 14:30

L16	235	(one adj shot) with mask with pattern$4	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/01/20 14:45
L17	1	(one adj shot) with mask with pattern$4 with wiring	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/01/20 14:31
L18	3	(one adj shot) with mask with pattern$4 with electrode	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/01/20 14:31
L19	5	(one adj shot) with mask with pattern$4 with conduct$5	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/01/20 14:35
L20	0	(one adj shot) with mask with pattern$4 with metal	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/01/20 14:36
L21	1	(one adj shot) with mask with metal	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/01/20 14:36
L22	2	((one adj shot) with mask with pattern$4) with gate	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/01/20 14:38
L23	7	(one adj shot) with mask with pattern$4 with layer	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/01/20 14:49
L24	674	((one single simple) adj (shot exposure)) with mask with pattern$4	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/01/20 14:50
L25	7	((one single simple) adj (shot exposure)) with mask with pattern$4 with wiring	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/01/20 14:50
L26	12	((one single simple) adj (shot exposure)) with mask with pattern$4 with (metal wiring)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/01/20 14:58
L27	1	((one single simple) adj (shot exposure)) with mask with pattern$4 with capacitance	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/01/20 14:58
L28	46	((one single simple) adj (shot exposure)) with mask with pattern$4 with operation$4	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/01/20 14:58